Refine Search

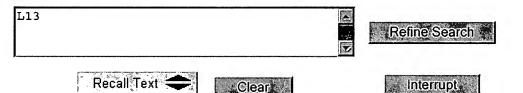
Search Results -

| Terms | Documents |
|---|-----------|
| (abrasive or polishing) and fluoride near5 salt and (acidic or ph) and ((polishing or polish or cmp) same (silica or silicon adj oxide or silicon adj dioxide or "sio.sub.2") same silicon adj nitride) | 37 |

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Search History

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IBM Technical Disclosure Bulletins

| <u>Set</u> | | U;4 | <u>Set</u> |
|-------------|---|-------|-------------|
| <u>Name</u> | Query | Count | <u>Name</u> |
| side by | | Count | result |
| side | | | set |
| DB = | PGPB, USPT, USOC, EPAB, JPAB, DWPI, TDBD; PLUR=YES; OP=ADJ | | |
| <u>L13</u> | (abrasive or polishing) and fluoride near5 salt and (acidic or ph) and ((polishing or polish or cmp) same (silica or silicon adj oxide or silicon adj dioxide or "sio.sub.2") same silicon adj nitride) | 37 | <u>L13</u> |
| <u>L12</u> | (abrasive or polishing) and fluoride near5 salt and ph and ((polishing or polish or cmp) same (silica or silicon adj oxide or silicon adj dioxide or "sio.sub.2") same silicon adj nitride) | 34 | <u>L12</u> |
| <u>L11</u> | L10 and (fluoride or fluorine) | 48 | <u>L11</u> |
| <u>L10</u> | (silica or silicon) near3 (film or layer) near20 silicon adj nitride near3 (film or layer) and abrasive near10 (silica or "sio.sub.2") and (ph or acidic) | 97 | <u>L10</u> |
| <u>L9</u> | L7 and (colloidal or sol) near2 (silica or silicon adj oxide or silicon adj dioxide or "sio.sub.2") | 31 | <u>L9</u> |
| <u>L8</u> | L5 and (colloidal or sol) near2 (silica or silicon adj oxide or silicon adj dioxide | 56 | <u>L8</u> |

| | or "sio.sub.2") | | | |
|--------------------------------|--|-----|-----------|--|
| <u>L7</u> | L6 and (polishing or cmp) | 192 | <u>L7</u> | |
| <u>L6</u> | (silica or silicon) near20 silicon adj nitride and (abrasive or polishing) near10 (silica or silicon or "sio.sub.2") and (fluorine near3 salt or ammonium adj2 fluoride or tetramethylammonium adj fluoride or tma adj salt or tma adj fluoride or "nh.sub.4 f") | 216 | <u>L6</u> | |
| <u>L5</u> | L4 and (polishing or cmp) | 123 | <u>L5</u> | |
| <u>L4</u> | (silica or silicon) near20 silicon adj nitride and (abrasive or polishing) near10 (silica or silicon or "sio.sub.2") and (fluoride near3 salt or halogen near3 salt or halide near3 salt) | 138 | <u>L4</u> | |
| <u>L3</u> | (silica or silicon) near10 silicon adj nitride and abrasive near10 silica and (fluoride near3 salt or halogen near3 salt or halide near3 salt) | 79 | <u>L3</u> | |
| <u>L2</u> | colloidal adj (silica or silicon or "sio.sub.2") and fluoride and ph and ((polishing or polish or mcmp) same (silica or silicon adj oxide or silicon adj dioxide or "sio.sub.2") same silicon adj nitride) | 39 | <u>L2</u> | |
| DB=PGPB,USPT; PLUR=YES; OP=ADJ | | | | |
| L1 | ammonium fluoride near5 water soluble | 16 | L1 | |

END OF SEARCH HISTORY